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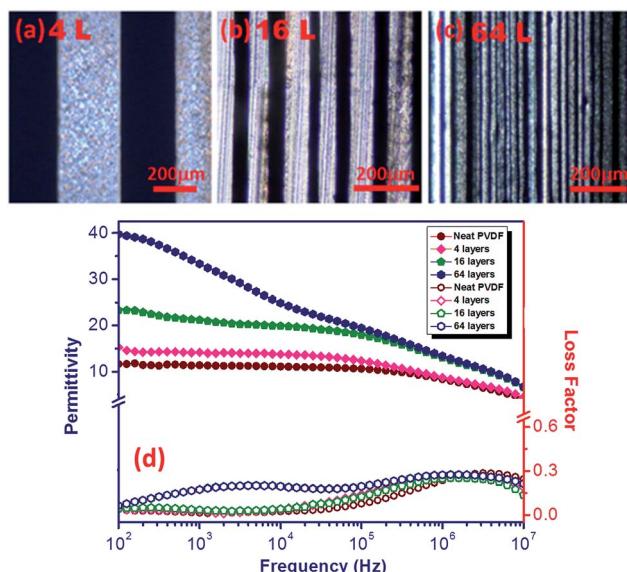
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## Correction: Dielectric hysteresis behaviors of polyvinylidene fluoride-based multilayer dielectrics controlled by confined distribution of conductive particles

 Jiaming Zhu,<sup>a</sup> Shanshan Luo,<sup>a</sup> Bo Cao,<sup>b</sup> Jiabin Shen<sup>\*a</sup> and Shaoyun Guo<sup>\*a</sup>

Correction for 'Dielectric hysteresis behaviors of polyvinylidene fluoride-based multilayer dielectrics controlled by confined distribution of conductive particles' by Jiaming Zhu *et al.*, *RSC Adv.*, 2015, 5, 65927–65931.

The authors apologise for inserting an incorrect image for Fig. 1 into the proof version of the original manuscript. The correct version of Fig. 1 is shown below.



**Fig. 1** (a–c) POM images of 4-, 16- and 64-layer PVDF/cPVDF specimens; (d) dielectric permittivity and loss factor of PVDF/cPVDF multilayer dielectrics and neat PVDF as a function of frequency.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

<sup>a</sup>State Key Laboratory of Polymer Materials Engineering, Polymer Research Institute of Sichuan University, Chengdu 610065, P. R. China. E-mail: shenjb@scu.edu.cn; Fax: +86-28-85466255; Tel: +86-28-85466077

<sup>b</sup>Department of Materials Science & Engineering, University of Washington, Seattle, Washington 98195, USA